



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Arie Hendrik Frans VAN VLIET et al.

Group Art Unit: 1733

Application No.: 09/352,612

Examiner: T. Kilkenny

Filed: July 13, 1999

Docket No.: 102222.01

For: GRID COMPRISING POLYMERIC, DRAWN STRIPS AND A PROCESS FOR
MAKING SAME

PRELIMINARY AMENDMENT

Director of the U.S. Patent and Trademark Office
Washington, D.C. 20231

Sir:

After entering Applicants' August 30, 2001 Amendment After Final Rejection, please amend the above-identified application as follows prior to initial examination on the merits:

IN THE CLAIMS:

Please add new claims 13-18 as follows:

--13. The grid of claim 1, wherein said at least one zone of overlap comprises at least two spatially separated bonding lines.--

--14. The grid of claim 1, wherein said at least one zone of overlap has a surface area of about a product of a width of the strips multiplied by the width of the strips.--

--15. The grid of claim 1, wherein the grid has a strength about equal to the higher tensile strength in the lengthwise direction of the strips.--

--16. A grid comprising drawn polymeric strips in at least two different directions, wherein the strips have a higher tensile strength in a lengthwise direction of the strips